

Electronic Patent Application Fee Transmittal

Application Number:	10554380			
Filing Date:	29-Sep-2006			
Title of Invention:	POSITIVE PHOTORESIST COMPOSITION AND METHOD FOR FORMING RESIST PATTERN			
First Named Inventor/Applicant Name:	Takuma Hojo			
Filer:	Neil S. Bartfeld/Aaron Dunn			
Attorney Docket Number:	SHIGA7.032APC			
Filed as Large Entity				
U.S. National Stage under 35 USC 371 Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Utility Appl issue fee	1501	1	1440	1440
Publ. Fee- early, voluntary, or normal	1504	1	300	300

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Extension-of-Time:				
Miscellaneous:				
Printed copy of patent - no color	8001	10	3	30
Total in USD (\$)				1770